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Substitute for form 1449A/PTO				Complete if Known	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT				Application Number	09/680777
				Filing Date	10/06/2000
				First Named Inventor	Jonathan F. Gorrell et al.
				Group Art Unit	1746
				Examiner Name	
Sheet	2	of	2	Attorney Docket Number	SC11210ZP

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GROUP 1700

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS						
Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.				T ²
<i>AB</i>	BC	PAUL, O. et al.; Sacrificial Aluminum Etching for CMOS Microstructures; pages 523-528; 0-7803-3744-1/97; IEEE				
<i>AB</i>	BD	ROGER T. HOWE; Applications of Silicon Micromachining to Resonator Fabrication; IEEE International Frequency Control Symposium; 1994; pages 2-7; 0-7803-1945-1/94; IEEE				
<i>AB</i>	BE	International Search Report				

Examiner Signature	<i>Alan Ober</i>	Date Considered	<i>2/16/04</i>
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation, if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Unique citation designation number. ² Applicant is to place a check mark here if English Language Translation is attached.



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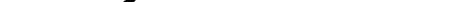
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Substitute for form 1449A/PTO				Complete if Known	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(use as many sheets as necessary)</i>				Application Number	09/680777
				Filing Date	10/06/2000
				First Named Inventor	Jonathan F. Gorrell et al.
				Group Art Unit	1763
				Examiner Name	Olsen
Sheet	1	of	2	Attorney Docket Number	SC11210ZP

U. S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

Examiner Signature		Date Considered	2-16-04
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation, if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹ Unique citation designation number. ² See Kinds of U.S. Patent Documents. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. ⁶ Applicant is to place a check mark here if English Language Translation is attached.

X4
Form PTO-1449

LIST OF PATENTS AND PUBLICATIONS
FOR
APPLICANT'S INFORMATION
DISCLOSURE
STATEMENT
(Use Several Sheets if Necessary)

ATTY. DOCKET NO.

SC11210ZP

SERIAL NO.

09/680,777

Jonathan F. Gorrell et al.

FILING DATE

GROUP 1763

October 6, 2000

REFERENCE DESIGNATION
U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	ISSUE DATE	NAME	CLASS	SUBCLASS	FILING DATE
AA						
AB						
AC						
AD						
AE						
AF						
AG						
AH						
AI						
AJ						
AK						
AL						
AM						
AN						

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	GRANT DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES	TRANSLATION NO
AO						<input type="checkbox"/>	<input type="checkbox"/>
AP						<input type="checkbox"/>	<input type="checkbox"/>

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

	AQ	Gregory Mulhern et al., "Supercritical Carbon Dioxide Drying of Microstructures", The 7th Int'l Conference on Solid-State Sensors and Actuators - Digest of Technical papers, June 7-10, 1993, Pages 296-299.
	AR	

EXAMINER



DATE CONSIDERED

2/16/04

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